Room-temperature relaxor ferroelectricity and photovoltaic effects in tin titanate directly deposited on a silicon substrate

Radhe Agarwal, Yogesh Sharma, 2,3,* Siliang Chang, Krishna C. Pitike, Changhee Sohn, Serge M. Nakhmanson, S Christos G. Takoudis, ^{4,6} Ho Nyung Lee, ³ Rachel Tonelli, ⁷ Jonathan Gardner, ⁷ James F. Scott, ⁸ Ram S. Katiyar, and Seungbum Hong^{2,9,†}

¹Department of Physics and Institute for Functional Nanomaterials, University of Puerto Rico, San Juan, Puerto Rico 00931, USA ²Material Science Division, Argonne National Laboratory, Lemont, Illinois 60439, USA

³Oak Ridge National Laboratory, Oak Ridge, Tennessee 37831, USA

⁴Department of Chemical Engineering, University of Illinois at Chicago, Chicago, Illinois 60607, USA ⁵Department of Materials Science and Engineering, Institute of Materials Science, University of Connecticut, Storrs, Connecticut 06269, USA

⁶Department of Bioengineering, University of Illinois at Chicago, Chicago, Illinois 60607, USA ⁷School of Chemistry, University of St. Andrews, St. Andrews KY16 9ST, United Kingdom ⁸School of Physics and Astronomy, University of St. Andrews, St. Andrews KY16 9SS, United Kingdom ⁹Department of Materials Science and Engineering, KAIST, Daejeon 34141, Republic of Korea



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Tin titanate (SnTiO₃) has been notoriously impossible to prepare as a thin-film ferroelectric, probably because high-temperature annealing converts much of the Sn²⁺ to Sn⁴⁺. In the present paper, we show two things: first, perovskite phase SnTiO₃ can be prepared by atomic-layer deposition directly onto p-type Si substrates; and second, these films exhibit ferroelectric switching at room temperature, with p-type Si acting as electrodes. X-ray diffraction measurements reveal that the film is single-phase, preferred-orientation ferroelectric perovskite SnTiO₃. Our films showed well-saturated, square, and repeatable hysteresis loops of around $3 \mu \text{C/cm}^2$ remnant polarization at room temperature, as detected by out-of-plane polarization versus electric field and field cycling measurements. Furthermore, photovoltaic and photoferroelectricity were found in Pt/SnTiO₃/Si/SnTiO₃/Pt heterostructures, the properties of which can be tuned through band-gap engineering by strain according to first-principles calculations. This is a lead-free room-temperature ferroelectric oxide of potential device application.

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I. INTRODUCTION

SnTiO₃ has been predicted to be a room-temperature ferroelectric with large polarization [1-3]. However, it has been difficult or impossible to process [4]. The Cambridge group found that only ilmenite phase formed [4], and in general, high-temperature processing and annealing may convert most of the Sn²⁺ to Sn⁴⁺. Therefore, we studied its production via low-temperature atomic-layer deposition (ALD) [5].

We emphasize that unlike ferromagnetism, ferroelectricity is not strictly a property of a material but of a system consisting of a dielectric and electrodes. To demonstrate switching, it may be necessary, for example, to have blocking electrodes rather than Ohmic in order to minimize leakage currents and obtain useful hysteresis curves. In the present case, we demonstrate switching for SnTiO₃ directly on conducting p-type Si, which acts as both substrate and electrode. Si electrodes were first used in ferroelectric thin-film devices by the IBM San Jose group in the 1970s [6], and they are

There are known artifacts that can look like ferroelectric switching: Pintilie and Alexe [8] have shown that back-to-back diodes produce a polarization versus voltage (P-V) hysteresis curve that closely resembles true ferroelectricity. However, there are two ways to discriminate unambiguously between such artifacts and true ferroelectric switching hysteresis. First, artifacts consisting of charge injection have hysteresis curves that move clockwise with time [9], which is impossible for true ferroelectric hysteresis; and second, back-to-back diodes (for example, the Si/SnTiO₃ interfaces in our systems) will not exhibit a Curie temperature above which hysteresis disappears. In the present work, we demonstrate both of these requirements (counterclockwise hysteresis and a measured Curie temperature) to prove true ferroelectricity at room temperature.

There is no reason to be skeptical of the present results on SnTiO₃ synthesis, since both the x-ray diffraction (XRD) and scanning electron microscopy (SEM) [5] measurements closely match those reported previously from powder data [10,11], which showed 100-nm-diameter

well understood. The main difference compared with metal electrodes is the longer screening length for depolarization fields [7].

^{*}Corresponding author: sharmay@ornl.gov

[†]Corresponding author: seungbum@kaist.ac.kr

single-phase nanocrystals with $T_C = 628 \, \mathrm{K}$ (close to the frequency-dependent relaxor $T_C = 600 \, \mathrm{K}$ we measure). However, the earlier work was not commercially viable since it requires a highly toxic TiCl₄ precursor. Moreover, $\mathrm{Sn^{2+}}$ in the powder prepared, due to disproportionation to $\mathrm{Sn^{4+}}$ and metallic Sn, might not easily survive the sintering process requisite to make pellets or films for devices.

It has been reported that $SnTiO_3$ has an optical band gap lying in the visible region of ~ 2 eV or even lower, which makes it a good candidate for photoferroelectric materials [12,13]. Photoferroelectric materials are particularly interesting due to coupling between photosensitivity and ferroelectric properties, which provide a large possibility of optoelectronics and solar energy harvesting applications [14–18]. However, there are very few useful photoferroelectric materials because most ferroelectrics have wide optical band gaps (>3 eV). Therefore, experimental values of the direct optical band gap in $SnTiO_3$ thin films were also compared with theoretical values calculated from density-functional theory (DFT). We have observed photoferroelectricity and a photovoltaic effect in our $Pt/SnTiO_3/p$ - $Si/SnTiO_3/Pt$ capacitor structures.

II. METHODS

A. Experimental details

SnTiO₃ thin films of 40 nm thickness were deposited on p-Si substrates [p-type Si (100) substrates (resistivity: $1-10 \Omega$ cm, 20×20 mm²)] using the atomic-layer-deposition (ALD) technique as detailed in Ref. [5]. Pt top electrodes were deposited on ALD-grown SnTiO₃ thin films using the rf-magnetron sputtering technique. X-ray diffraction (XRD) was performed with a PANalytical Empyrean diffractometer operating in reflection mode using monochromated Cu $K\alpha_1$ radiation. XRD data were collected from 2θ values of 10° -120° with a step size of 0.017°. Total data collection time was 90 min. Macroscopic ferroelectric properties were investigated with a ferroelectric tester (TF Analyzer 2000, aixACCT). To examine the intrinsic fatigue behavior, 10- μ s-wide electric pulses with a frequency of 10 kHz were applied to the Pt-top electrode. An incandescent lamp was used as a source to measure light-induced changes in ferroelectric hysteresis loops. Photovoltaic measurements were performed using a Keithley-2401 electrometer under a 1-sun AM 1.5 solar simulator with light source density $\sim 1 \text{ kW/m}^2$. Conduction mechanisms in Pt/SnTiO₃/p-Si/SnTiO₃/Pt capacitors were studied through current-voltage (I-V) measurements using a Keithley 2401 source-meter unit. Temperaturedependent measurements were done using a programmable Joule-Thompson thermal stage system (MMR model no. K-20). Dielectric measurements between frequencies 500 Hz and 300 kHz were done using an impedance analyzer HP4924A. An M-2000 ellipsometer (J. A. Woollam Co.) was employed to record two ellipsometric parameters, ψ and δ , of SnTiO₃ film on *p*-type Si substrate. Then a two-layer model composed of the substrate and film was used to determine the optical constants of the films. The optical constants of the substrate as well as the film thickness were obtained separately and fixed during the fitting procedure.

B. Theoretical methods

A computational study was conducted to evaluate the band gap of the polar perovskite SnTiO₃ subjected to epitaxial strain following the approach outlined in Ref. [12]. DFT [19,20] calculations were performed using the Vienna ab initio Simulation Package (VASP) [21,22] within the local density approximation (LDA), parametrized by Perdew and Zunger [23]. The projector-augmented plane-wave method [24,25] simulated the core and valence electrons. A plane-wave basis supporting the wave-function cutoff at 900 eV was used to converge the total energy of the system to within 1 meV/f.u. Zone-edge-shifted $8 \times 8 \times 8$ Monkhorst-Pack (MP) [26] k-point mesh was used for the Brillouin-zone (BZ) integration. Force components on individual ions were relaxed to less than 1 meV/Å and stress-tensor components on the simulation cell to less than 0.1 kbar in all the structures studied. The monoclinic angle (β) was not allowed to relax in the monoclinic Cm phase. The biaxial misfit strain was defined as $\varepsilon = \frac{a}{a_0} - 1$, where a_0 corresponds to the optimized lattice parameter of the cubic $Pm\bar{3}m$ structure with all the normal stresses relaxed to values less than 0.1 kbar. It is well known that the LDA exchange correlation functional underestimates the value of the band gap. We have therefore computed more accurate values of the perovskite SnTiO₃ band gaps using the Heyd-Scuseria-Ernzerhof (HSE) screened hybrid functional [27].

III. RESULTS AND DISCUSSION

X-ray diffraction (XRD) measurements were carried out to study the structural characteristics of our thin films. XRD patterns recorded at ambient conditions showed that the film is single-phase, preferred-orientation ferroelectric perovskite SnTiO₃ (Fig. S1 of the Supplemental Material). Based on the XRD data, we can predict that our films have grains with several orientations of (101), (011), (211), and (100) with *c/a* ratios of 1.144, 1.146, 1.036, and 1.061, respectively (see the Supplemental Material) [28,29].

Polarization–electric-field (P-E) hysteresis loop measurements were done on Pt/SnTiO₃/p-Si/SnTiO₃/Pt capacitors at different applied voltages, as shown in Fig. 1(a). The inset of Fig. 1(b) represents the schematic of Pt/SnTiO₃/p-Si/SnTiO₃/Pt capacitor structure used for ferroelectric and photovoltaic measurements. P-E hysteresis loops in Fig. 1(a) clearly indicate the presence of room-temperature ferroelectricity with a well-defined remnant polarization and coercive field. The saturated (P_s) and remnant polarization (P_r) values were found to be \sim 7.5 and 3.3 μ C/cm², respectively, at room temperature and 40 kHz frequency.

From Fig. 1(a), a clear hysteresis switching current characteristic with a nest of loops, one inside the other, was observed with increasing applied voltages. The inset of Fig. 1(a) displays the direction of the hysteresis curve as a function of time, which is counterclockwise and thus excludes the possibility of artifacts consisting of charge injection, which sometimes mimic ferroelectric-like behavior [9]. Some preliminary work on ferroelectric hysteresis was also done in an earlier report [5]. The authors switched via an AFM tip and obtained very reproducible fully saturated switching loops at a coercive field of 4 V across 40 nm. This value of $E_c = 100 \,\mathrm{MV/m}$ is very

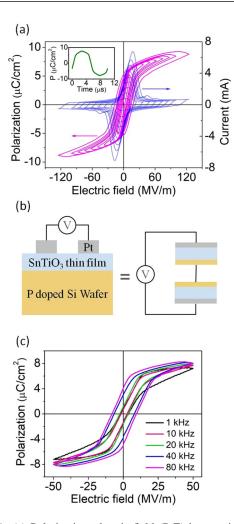


FIG. 1. (a) Polarization–electric-field (P-E) hysteresis loop and switching current at different applied voltages between 1 and 10 V measured at room temperature. The inset shows the direction of a hysteresis loop as a function of time. (b) Schematic diagram of the Pt/SnTiO₃/p-Si/SnTiO₃/Pt capacitor structure used for electrical measurements. (c) Frequency dependence of P-E hysteresis loops.

reasonable for perovskite oxides and compares with about 20 MV/m in the present work. The present data are better than those of earlier work [5] because we have a parallel-plate capacitor structure and can therefore estimate the electroded area, whereas no quantitative value of polarization could be obtained from the AFM-tip switched data of the earlier work. Perhaps most important in the present context, the hysteresis data of earlier work [5] are on an asymmetric Si/SnTiO₃/AFMtip geometry and not on a Si/SnTiO₃/Si symmetric sandwich. Therefore, the hysteresis data cannot arise from a backto-back diode artifact, as discussed by Pintillie and Alexe [8]. We have also measured capacitance-voltage curves on a single metal-oxide-semiconductor (MOS, Pt/SnTiO₃/Si) and two back-to-back connected MOS (Pt/SnTiO₃/Si/SnTiO₃/Pt) -based capacitor structures of SnTiO₃ film (see the Supplemental Material, Fig. S2) [28,30-32], where the presence of two capacitance peaks attests to the fact that we are observing ferroelectric switching even in the MOS structure [30–32]. More interestingly, we observed the presence of two capacitance peaks (maxima) in a more symmetric way for the case of two back-to-back connected MOS structure, revealing a true ferroelectric property of our SnTiO₃ films.

Moreover, to exclude any possibility of charge injection and electret effect due to trapped charges at the Si/SnTiO₃ interface, we measured the frequency dependence of P-E hysteresis loops as shown in Fig. 1(c). The frequency dependence of the P-E hysteresis loop illustrates clear polarization switching at higher frequencies (up to 80 kHz). Such frequency-dependent behavior eliminates the possibility of a back-to-back diode effect, where the response at such high frequencies is not feasible for electrets since slow motion of ions is required. In addition, a temperature-dependent P-E hysteresis loop and polarization measurement using the positive-up-negative-down (PUND) technique were also performed to confirm the ferroelectric nature of our thin film, as shown in Fig. S3 of the Supplemental Material [28].

In Fig. 1(c), a drastic change in P_r values from low (\leq 20 kHz) to high (\geq 40 kHz) frequencies was observed, whereas there was little change in P_s (the extrapolated value at E=0 axis) as a function of frequency. The internal bias field created at each MOS structure will tend to stabilize polarization with the opposite direction [see Fig. 1(b)] due to their back-to-back connection. As such, at low frequency, our Pt/SnTiO₃/Si/SnTiO₃/Pt structure will suffer from backswitching phenomena resulting in very low net remnant polarization. However, at high frequency, the depletion will not play a significant role, so there will be negligible backswitching phenomena in the structure, resulting in high remnant polarization. We speculate that this is why we see a drastic change in P_r in a stepwise fashion from 20 to 40 kHz, while we see a small change in P_s as a function of frequency in Fig. 1(c).

Temperature-dependent current (*I*) versus voltage (*V*) curves were measured from 83 to 600 K to understand the electrical conduction mechanism in Pt/SnTiO₃/*p*-Si/SnTiO₃/Pt capacitors as shown in Fig. 2(a). To reveal the dominant

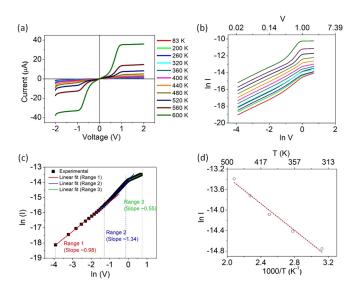


FIG. 2. (a) *I-V* characteristics of Pt/SnTiO₃/*p*-Si/SnTiO₃/Pt capacitors at various temperatures. (b) ln*I*-ln*V* plots at various temperatures. (c) ln*I*-ln*V* plot at 300 K exhibits trap-assisted space-charge-limited current (SCLC) behavior of current transportation. (d) Arrhenius plot for capacitor structure.

conduction mechanism of charge transport, the temperaturedependent I-V curves were plotted on a logarithmic scale, as shown in Figs. 2(b) and 2(c). As can be seen from Fig. 2(c), the logarithmic *I-V* plot at room temperature can be fitted into three regimes, where the low and intermediate regimes are thought to arise from Ohmic conduction and Child's square law, respectively, and the high-voltage region corresponds to a steep increase in current [33]. Based on such I-V behavior, the conduction mechanism in our films is likely to be trap-assisted space-charge-limited current conduction [34]. However, it has often been observed in oxide thin films that a linear I-V relation at low applied voltages can also be explained by Simmons' modified Schottky emission mechanism. Unambiguous discrimination of these mechanisms will require thicknessdependent current measurements for further clarification [35]. At present, however, the temperature dependence of current can be used to determine the depth of the trapping levels. The slope of $\ln I$ versus 1/T, which is $(E_c - E_t)/k$, provides the activation energy value, as shown in Fig. 2(d). We found that deep trap levels exist in the film with an activation energy of 1.3 \pm 0.1 eV. This value is reasonable for oxygen-vacancy transport in perovskite oxides, including SrTiO₃, where 1.1 eV is the most common value [36,37]. This value is found in two ways: From the $\ln I$ versus (1000/T) graph in Fig. 2(d) and, less precisely, as the kink and steep increase in current of the lnI versus $\ln V$ curve in Fig. 2(c) near $\ln V = 0$ (i.e., V = 1 V).

It is important to rule out charge injection as a source of artifacts. In addition to noting that the polarization hysteresis

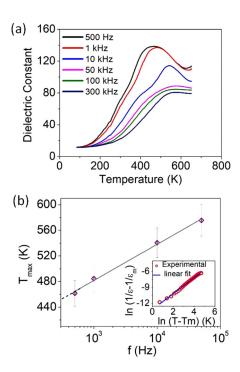


FIG. 3. (a) Temperature dependence of the dielectric constant. (b) Extrapolated freezing temperature was observed to be \sim 452 K. The inset shows the linear fitting of experimental data obtained from modified Curie-Weiss law. We note that for any relaxor, as the probe frequency is lowered, the temperature corresponding to dielectric constant peaks must decrease and the peak magnitude must increase; in any viscous material, the susceptibility (both electrical and mechanical) must increase as frequency decreases.

loops are saturated, we provide in Fig. 3 data showing a dielectric peak at $T_C = 450-600 \,\mathrm{K}$, depending upon probe frequency from \sim 500 Hz Hz to 300 kHz. These data display the signature of a relaxor ferroelectric and satisfy a Vogel-Fulcher relationship with an extrapolated freezing temperature of \sim 452 K [Fig. 3(b)], suggesting local disordering of the Sn^{2+}/Sn^{4+} ions. The inset of Fig. 3(b) shows the relationship between dielectric constant and temperature near freezing, which is described by the modified Curie-Weiss law [38]. A plausible hypothesis for the observed glassy behavior is the presence of some Sn⁴⁺ at the Ti⁴⁺ perovskite B-site. This could be tested via XPS measurement of the Sn⁴⁺/Sn²⁺ ratio. Since all these temperatures are well above ambient, these properties do not detract from the potential for commercial devices. Parenthetically, the Vogel-Fulcher behavior also helps rule out any artifacts as explanations of the hysteresis curves discussed above.

We have also observed the photovoltaic effect in Pt/SnTiO₃/p-Si/SnTiO₃/Pt capacitors. In the dark, a very small current $(10^{-4} \mu A)$ at zero bias voltage could be detected. Under white light illumination, a distinct photovoltaic behavior was observed with short circuit current $(J_{SC}) = 3 \mu A$ and open circuit voltage $(V_{OC}) = 0.13 \,\text{V}$, as shown in Fig. 4(a). V_{OC} and $J_{\rm SC}$ were measured as a function of time over multiple on/off light cycles, showing good retention over time, with instability in $V_{\rm OC}$ and $J_{\rm SC}$ displaying a sudden increase and then a return to initial values, as shown in Fig. 4(b). To explain the unstable nature of J_{SC} in multiple light on/off cycles, we measured the variation in J_{SC} under continuous light illumination of 120 s, as shown in Fig. S4 of the Supplemental Material [28]. We observed a continuous increase in photocurrent under continuous light illumination, which could be attributed to the presence of trap levels due to the structural defects, mainly oxygen vacancies [39,40]. Under the light illumination, photogenerated electrons are transferred to the conduction band and some of them occupy the deep trap levels. Photocurrent starts increasing slowly as the trap levels are filled gradually. In addition, we have also observed photosensitivity of our samples in the ultraviolet (UV) region. The photovoltaic behavior of SnTiO₃ films under UV-light illumination has been shown in Fig. S5 of the Supplemental Material [28,41]. There may be a small effect of the Si substrate on the photovoltaic effect but very limited as the photovoltaic effect from the Si/SnTiO₃ interfaces will be canceled out due to the nature of back-to-back connection, and only the ferroelectric part will contribute to the photovoltaic effect as the ferroelectric polarization will be aligned in the direction from one Pt electrode to the other. To further confirm the contribution from the Si substrate, we measured *I-V* curves under the illumination of a red laser pen (~650 nm) and we observed a negligible contribution from Si in the overall photovoltaic effect (see the supplemental material, Fig. S6) [28].

Moreover, polarization fatigue, which is an important factor to determine the switchability of remnant polarization over the field cycles, was also measured with 10- μ s-wide electric pulses at a frequency of 10 kHz. Figure 4(c) shows the evolution of remnant polarization of SnTiO₃ as a function of switching cycles. We confirmed a nearly fatigue-resistant characteristic up to 10^6 cycles in our SnTiO₃ capacitor, which is comparable to early studies of Pt/Pb(Zr, Ti)O₃/Pt capacitors

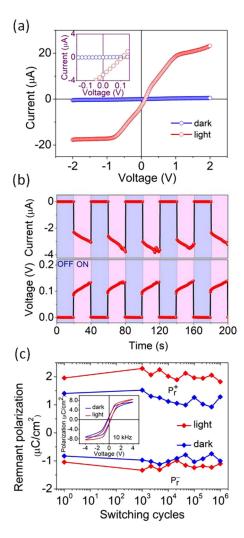


FIG. 4. (a) *I-V* characteristics of a Pt/SnTiO₃/p-Si/SnTiO₃/Pt capacitor in dark and under white light illumination. The inset shows the portion of the *I-V* curves around zero field, revealing $J_{\rm SC}$ and $V_{\rm OC}$ to be 3 μ A and 0.13 V, respectively. (b) The time dependence of $J_{\rm SC}$ and $V_{\rm OC}$ was measured under multiple on/off light cycles. (c) The evolution of remnant polarization with the number of bipolar cycles in dark and light. The inset shows the PE hysteresis loops after 10^6 switching cycles.

[42]. Interestingly, we have also observed the photoferroelectric effect in Pt/SnTiO₃/p-Si/SnTiO₃/Pt capacitor structures, where enhancement in ferroelectric properties was observed with an increase in P_s and P_r values under white light illumination. Such enhanced ferroelectric behavior shows the photoferroelectric nature of SnTiO₃ thin films.

A combination of experimental and computational techniques was utilized to evaluate the optical band gap of SnTiO₃. We measured the refractive indices of the film samples, n and k, using the spectroscopic ellipsometry technique, and we calculated the absorption coefficient, α . The (direct) band gap was determined to be 2.6 eV by linearly extrapolating $(\alpha E)^2$ versus photon energy (E), as indicated by a gray line in Fig. 5(a) [43].

In such oxides, strain imposed by substrates could be an important factor to tailor the band gap. The electronic properties

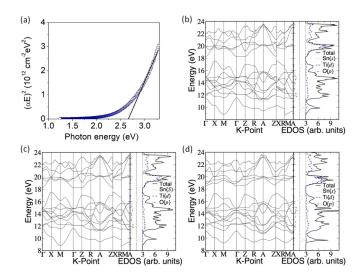


FIG. 5. (a) $(\alpha E)^2$ vs photon energy plot gives the direct band gap of 2.6 eV for SnTiO₃ thin films grown on p-Si substrate. A gray line is an extrapolation line to estimate the band gap. (b)–(d) Electronic band dispersion (left panel) and ion and l quantum-number-resolved electronic density of states (EDOS) (right panel) calculated for SnTiO₃ for the biaxial misfit strain ε of (b) -0.33%, (c) 0%, and (d) 0.33% within the local density approximation (LDA). The location of the bands is referenced with respect to the low-lying O 2s state, which is assumed to be undisturbed by any structural distortions.

of perovskite SnTiO₃, including the band-gap values, the band structure, and the electronic density of states (EDOS), were investigated for varying epitaxial strain ε . Figures 5(b)–5(d) show an electronic band dispersion diagram (left panel) and EDOS (right panel) of SnTiO₃ obtained within the LDA for (b) $\varepsilon = -0.33\%$, (c) $\varepsilon = 0\%$, and (d) $\varepsilon = +0.33\%$, i.e., throughout the region where a transition from P4mm to Cm structure accompanied by a large band-gap change was predicted by the previous investigation [12]. The band gap remains indirect (from X to Γ) for all the considered strains, with the value changing from ~ 0.5 (compression) to 1.0 eV (tension), as previously reported [12]. We also included ion and l quantum-number-resolved EDOS for the aforementioned three epitaxial strain states. Valence bands between 16 and 17 eV are composed of Sn s and O p states. Conduction bands between 19 and 21 eV are largely composed of Ti d states with a small mixture of O p states. It is well known that the LDA exchange correlation functional underestimates the value of the band gap. We computed more accurate values of the perovskite SnTiO₃ band gaps using the HSE screened hybrid functional (see the Supplemental Material, Fig. S7) [28], obtaining values of 2.175 eV for the P4mm phase under compressive and zero strains, and 2.655 eV for the Cm phase stabilized in epitaxial tension. The band-gap value predicted by the HSE-based calculation for the monoclinic Cm phase is in close agreement with that determined by the experimental techniques, although at this point the nature of the band gap is not clear since the experiment data point toward a direct band gap while the theory suggests an indirect band gap. The plot of the strain-dependent band gap based on EDOS suggests that we need to enhance tensile strain inside SnTiO₃ film to further lower the optical band gap, which will enhance the photoferroelectric property of the film (see the Supplemental Material, Fig. S7) [28].

IV. CONCLUSION

In summary, we demonstrated room-temperature relaxor ferroelectricity and photovoltaic effects in SnTiO₃ thin films deposited directly on the p-type Si substrates. XRD data, polarization-electric-field hysteresis loop and permittivity measurements, dependence of dielectric peaks at $T_C =$ $450-600 \,\mathrm{K}$ on probe frequency from $\sim 500 \,\mathrm{Hz}$ to $300 \,\mathrm{kHz}$, and a Vogel-Fulcher relationship with an extrapolated freezing temperature of \sim 452 K confirm the presence of relaxor ferroelectric perovskite SnTiO₃ in our films. Furthermore, photovoltaic and photoferroelectricity were manifested in Pt/SnTiO₃/Si/SnTiO₃/Pt heterostructures, of which properties can be tuned through optical band-gap engineering by strain according to the first-principles calculations. This study provides a path to develop green material for various ferroelectric- and dielectric-based emerging nanoelectronic devices and photoferroelectric applications [44,45].

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